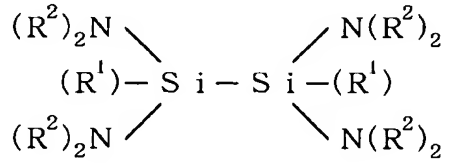
REMARKS

Reconsideration of this application is respectfully requested. Claims 1-10 are pending and at issue.

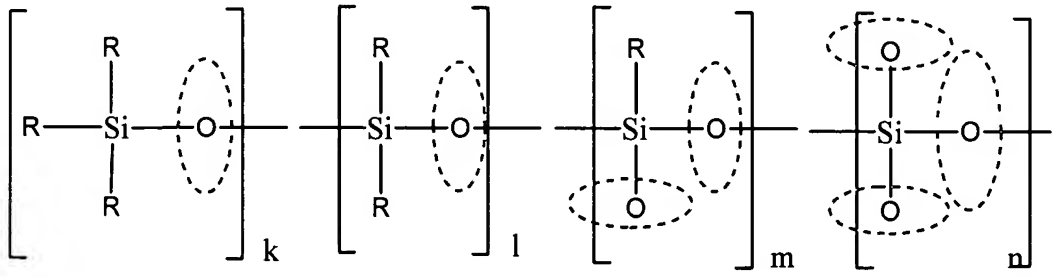
Rejections Under 35 U.S.C. § 102(b) and § 103

Claims 1-10 stand rejected as anticipated by Nakano et al. (U.S. Patent No. 5,840,821). The Examiner asserts that Nakano teaches a coating solution containing the compound:



..... (1)

wherein R^1 represents a hydrogen or a methyl group, and R^2 represents a methyl group, an ethyl group, a propyl group or a tertiary butyl group. Applicants respectfully disagree with this assertion. To the contrary, Nakano teaches a siloxane oligomer, one of which is shown below:



wherein R is a saturated or unsaturated hydrocarbon. The compound recited in claim 1 has no oxygen atoms, and the silicone atom is bound to nitrogen atoms. The compound of claim 1 is a different class of compound than that disclosed by Nakano.

Claims 1-10 stand rejected as obvious over Nakano in view of Lukas (U.S. Published Patent Application No. 2004/0096672. Lukas discloses a film that consists essentially of silicone, carbon, oxygen, hydrogen and fluorine (see Lukas, paragraph 29). As explained above, the compound of

claim 1 has no oxygen atoms and the silicone atoms are bound to nitrogen atoms. Neither Nakano nor Lukas teach or suggest the compound of claim 1. Applicants request that this rejection be withdrawn.

In view of the above remarks, applicant believes the pending application is in condition for allowance.

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Respectfully submitted,

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